Appl. No. 10/781,158

Filing Date: February 17, 2004

This listing of claims will replace all prior versions, and listings, of claims in the application:

Listing of Claims:

1. (Currently amended) A process for preparing a compound of formula (I):

$$XH \cdot H_2N + H \cdot S$$

$$CO_2R^1 \qquad (I)$$

wherein R¹ is para-nitrobenzyl or allyl; and X is halo,; comprising the steps of:

a) eyelizing a trimethylphosphinie reacting a compound of formula (IIIa)(IIIc):

wherein

R¹ is para-nitrobenzyl-or allyl; and

 R^2 is selected from the group consisting of C_{1-6} alkyl, C_{6-10} aryl, C_{6-10} aryl C_{1-6} alkyl and dithianyl, with a halogenating agent, in a solvent and in the presence of a base,

to form a compound of formula (II)(IIIb):

$$\begin{array}{c|c}
R^2 & H & H \\
\hline
CO_2R^1 & (III)
\end{array}$$

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wherein

R¹ is para-nitrobenzyl, or allyl;

 R^2 is selected from the group consisting of C_{1-6} alkyl, C_{6-10} aryl, C_{6-10} aryl C_{1-6} alkyl and dithianyl, and X' is halo; and

b) reacting said compound of formula (III) with trimethylphosphine, in a solvent and in the presence of a base, to form a trimethylphosphinic compound of formula (IIIa):

wherein R¹ is para-nitrobenzyl and R² is selected from the group consisting of C₁₋₆alkyl, C₆₋₁₀aryl, C₆₋₁₀arylC₁₋₆alkyl and dithianyl;

c) cyclizing said compound of formula (IIIa) in a solvent to form a compound of formula (III):

wherein R¹ is para-nitrobenzyl and R² is selected from the group consisting of C₁₋₆alkyl, C₆₋₁₀aryl, C₆₋₁₀arylC₁₋₆alkyl and dithianyl; and

- d) treating said compound of formula (II) with a Lewis acid of structure PX₅ wherein X is a-halo-group.
- 2. (Currently amended) A process according to claim 1, wherein said solvent in step (c) is selected from the group consisting of toluene, xylene, tetrahydrofuran, methylene chloride and acetonitrile.

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- 3. (Currently amended) A process according to claim 1, wherein said acid <u>in step (d)</u> is phosphorus pentachloride or phosphorus pentabromide; and wherein X is chloro or bromo.
- (Canceled)
- 5. (Currently amended) A process according to claim [[4]]1, wherein said solvent in step (b) is tetrahydrofuran, acetonitrile or methylene chloride.
- 6. (Currently amended) A process according to claim [[4]]1, wherein said base in step (b) is selected from the group consisting of imidazole, 2,6-lutidine, pyridine, N-methylmorpholine and sodium bicarbonate.
- 7. (Canceled)
- 8. (Currently amended) A process according to claim [[7]]1, wherein said halogenating agent in step (a) is thionyl chloride, thionyl bromide, phosphorus trichloride or phosphorus tribromide; and said halo-X' in step (a) is chloro or bromo.
- 9. (Currently amended) A process according to claim [[7]]1, wherein said base <u>in step (a)</u> is selected from the group consisting of pyridine, 2,6-lutidine, N-methylmorpholine and imidazole.
- 10. (Currently amended) A process according to claim 7, further comprising the step of A process for preparing a compound of formula (I):

wherein R¹ is para-nitrobenzyl and X is halo; comprising the steps of:

a) preparing said compound of formula (IHe), by reacting a compound of formula (V):

$$R^2$$
 C
 O
 O
 O
 CO_2R^1
 (V)

wherein said R^1 is para-nitrobenzyl or allyl-and said R^2 is selected from the group consisting of C_{1-6} alkyl, C_{6-10} aryl, C_{6-10} aryl C_{1-6} alkyl and dithianyl, $\frac{1}{5}$

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with a compound of formula (IV):

wherein Y is a leaving group selected from the group consisting of bromo, chloro, fluoro, iodo and tosylate; in a solvent; -to prepare a compound of formula (IIIc):

wherein R¹ is para-nitrobenzyl and R² is selected from the group consisting of C₁₋₆alkyl, C₆₋₁₀aryl, C₆₋₁₀arylC₁₋₆alkyl and dithianyl;

b) reacting said compound of formula (IIIc) with a halogenating agent, in a solvent and in the presence of a base, to form a compound of formula (IIIb):

wherein R^1 is para-nitrobenzyl, R^2 is selected from the group consisting of C_{1-6} alkyl, C_{6-10} aryl, C_{6-10} aryl C_{1-6} alkyl and dithianyl, and X' is halo;

c) reacting said compound of formula (IIIb) with trimethylphosphine, in a solvent and in the presence of a base, to form a trimethylphosphinic compound of formula (IIIa):

wherein R¹ is para-nitrobenzyl and R² is selected from the group consisting of C₁₋₆alkyl, C₆₋₁₀aryl, C₆₋₁₀arylC₁₋₆alkyl and dithianyl;

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d) cyclizing said compound of formula (IIIa) in a solvent to form a compound of formula (III):

wherein R¹ is para-nitrobenzyl and R² is selected from the group consisting of C₁₋₆alkyl, C₆₋₁₀aryl, C₆₋₁₀arylC₁₋₆alkyl and dithianyl; and

- e) treating said compound of formula (II) with a Lewis acid of structure PX₅ wherein X is halo.
- 11. (Currently amended) A process according to claim 10, wherein said Y in step (a) is bromo or chloro.
- 12. (Currently amended) A process according to claim 10 wherein said solvent in step (a) is selected from the group consisting of alcohol, wherein said alcohol is selected from the group consisting of methanol, ethanol and propanol; methylene chloride; acetone; dimethylformamide or mixtures thereof.
- 13-31. (Canceled)
- 32. (Currently amended) A compound of formula (I):

(I)

wherein R¹ is para-nitrobenzyl or allyl; and X is halo.

- 33. (Canceled)
- 34. (Currently amended) A compound of formula (IIIc):

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wherein R¹ is para-nitrobenzyl-or allyl; and

R² is selected from the group consisting of C₁₋₆alkyl, C₆₋₁₀aryl, C₆₋₁₀arylC₁₋₆alkyl and dithianyl. (C_6-C_{10}) aryl (C_{1-6}) alkyl;

K is hydroxy, halo or -P (CH₃)₃;

wherein the C K bond is a single bond when K is hydroxy or halo; and a double bond when K is P (CH₃)₃; and

wherein said compound of formula (III) is selected from the group consisting of compound of formulae (IIIa), (IIIb) and (IIIe):

35-39. (Canceled)

(New) A process according to claim 1, wherein: said solvent in step (c) is selected from the group consisting of toluene, xylene, tetrahydrofuran, methylene chloride and aceotnitrile, said

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acid in step (d) is phosphorus pentachloride or phosphorus pentabromide; said X in step (d) is chloro or bromo; said solvent in step (b) is tetrahydrofuran, acetonitrile or methylene chloride; said base in step (b) is selected from the group consisting of imidazole, 2,6-lutidine, pyridine, N-methylmorpholine and sodium bicarbonate; said X' in step (b) is chloro or bromo; said halogenating agent in step (a) is thionyl chloride, thionyl bromide, phosphorus trichloride or phosphorus tribromide; and said base in step (a) is selected from the group consisting of pyridine, 2,6-lutidine, N-methylmorpholine and imidazole.